

New York Microscopical Society
30 North Mountain Avenue
Montclair, NJ 07042

Bernard Friedman Memorial Workshop

Polarized Light Microscopy

May 3, 10, 17 & 24, 2008

An advanced course on polarized light microscopy which will cover the following topics:

The nature of polarized light
The origin and interpretation of interference colors
Birefringence and crystal orientation, The Indicatrix
Compensation and variable compensators
Interference figures and their interpretation

The workshop will consist of four Consecutive Saturdays of lectures and hands on labs to cover the theoretical and practical aspects of polarized light microscopy. The course instructors include Jan Hinsch formally of Leica, Inc., Mary McCann of McCann Imaging, John Reffner of Smiths Detection and N.Y.M.S. Instructor Don O'Leary.

WHEN: May 3, 10, 17 & 24, 2008 from 10 A.M. to 4 P.M.

WHERE: 30 North Mountain Avenue, Montclair, NJ 07042. Phone (973) 744-0043

COST: \$425 for N.Y.M.S. members, \$455 for non-members (includes membership). Lunch and course materials are included. Checks made out to N.Y.M.S.

WHO: advanced course for those who have completed "The Use of the Microscope" or are experienced in microscopy and familiar with the theory of its use.

HOW: Register using the form below. Limited to the first 12 registrants. Return form to Don O'Leary, 10 Sampson Street, Unit 113, Saddle Brook, NJ 07663

FURTHER INFORMATION: Call D. O'Leary (201)368-8849 e-mail dkoleary@verizon.net

PLEASE POST

Registration Form
Polarized Light Microscopy

N.Y.M.S. Member _____ (\$425) Non-Member _____ (\$455)

Name _____
Address _____
Phone (W) _____ (H) _____
e-mail _____